

Title (en)
A machine for the continuous plating and embossing of hides and the like

Title (de)
Maschine zum kontinuierlichen Plattieren und Prägen von Häuten und dergleichen

Title (fr)
Machine pour le placage et l'estampage continu des peaux ou similaires

Publication
EP 1024202 A3 20010307 (EN)

Application
EP 00100882 A 20000118

Priority
IT VI990013 A 19990127

Abstract (en)
[origin: EP1024202A2] The invention provides a machine (1) for the continuous plating and embossing of hides and the like, particularly suitable for processing hides tanned with the ecological system, which uses products that can be diluted in water and that require a reaction time to reticulate, in order to affix the plating and embossing action on the surface thereof, significantly greater than the times required by hides tanned with chemical solvents. The machine (1) is characterised by the fact that the plating and embossing action of the hide (4) is performed by winding and pressing it on an operating cylinder (2) by means of a belt (3) under tension, also partially wound on said cylinder (2) and placed externally thereto. <IMAGE>

IPC 1-7
C14B 1/56; **C14B 1/34**

IPC 8 full level
C14B 1/34 (2006.01); **C14B 1/56** (2006.01)

CPC (source: EP)
C14B 1/34 (2013.01); **C14B 1/56** (2013.01)

Citation (search report)
• [XA] EP 0095122 A2 19831130 - HACKER KURT
• [A] US 4065943 A 19780103 - DOKOUPIL JIRI, et al
• [A] US 4296514 A 19811027 - DOKOUPIL JIRI, et al

Cited by
CN107012267A; IT201600089851A1; ITUB20160895A1; CN100338232C; CN105936949A; WO2006100055A1; WO2005093104A1

Designated contracting state (EPC)
AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE

DOCDB simple family (publication)
EP 1024202 A2 20000802; **EP 1024202 A3 20010307**; IT 1307067 B1 20011023; IT VI990013 A1 20000727; KR 20010014454 A 20010226; TR 200000219 A2 20000821

DOCDB simple family (application)
EP 00100882 A 20000118; IT VI990013 A 19990127; KR 20000003753 A 20000126; TR 200000219 A 20000125